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The modulation of the electrical and optical properties of Cs₂TiBr₆ by doping

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As one of the most promising light absorbing-materials, all inorganic lead-free perovskite Cs₂TiBr₆ has obvious advantages, such as outstanding photoelectric properties, an adjustable band gap, and environmental friendliness. However, the wide band gap limits its application in optoelectronic devices. Here, the modulation of its electrical and optical properties by doping is investigated based on first-principles density functional theory (DFT). The elements Si, Ge, and Te are used to substitute Ti, and Br is substituted by Cl and I with different concentrations, respectively. Compared with the pristine material, Cs₂Ti_{0.5}Ge_{0.5}Br₆ has better physical stability, and a smaller band gap (1.33 eV). The light absorption is broadened obviously because of the states of 4s from Ge. Similarly, the band gap of Cs₂Ti(Br_{0.75}I_{0.25})₆ is 1.29 eV and its visible light absorption was enhanced due to the 5p electron of the I atom. Furthermore, the quasi-direct band gap of the original material is adjusted to the direct band gap, which approaches the optimum band gap. Our results indicate that doping modulation will greatly improve the prospects of the Cs₂TiBr₆ perovskite for application in solar cells.

1. Introduction

Solar energy has attracted more and more attention due to easy access and environmental protection.^{1–3} In the past decade, perovskite solar cells (PSCs) with low cost and easy fabrication have been developed rapidly.^{4,5} The manufacturing technology has been improved continuously, and the photoelectric conversion efficiency (PCE) has jumped from 3.8%⁶ in 2009 to 23.7%⁷ in 2019. However, a large number of toxic elements lead and organic cations with insufficient environmental tolerance are considered to be the main factors preventing their commercialization.⁸ Therefore, lead is replaced with other non-toxic or less toxic and environment-friendly transition metals, such as Sn, Bi, Sb, and Ti, to solve the toxicity problem.^{9,10} Replacing organic cations with cesium (Cs⁺) is a direction to solve the instability problem.^{11,12}

As a lead-free perovskite, Cs₂TiBr₆ shows strong adaptability under continuous sunlight or in humid environments due to the stable oxidation state of Ti atoms. In 2018, Ju *et al.*¹³ synthesized a Cs₂TiBr₆ perovskite material with a measured band gap value of 1.8 eV, and its energy band structure has a quasi-direct band gap because its band valleys at the Γ and X points were very close. In the same year, Chen *et al.*¹⁴ applied the material as the solar light

absorption layer for the first time. The unpackaged cell still maintained 90% of the original efficiency under the conditions of a temperature of 70 °C, a humidity of 30% and ambient light irradiation for 350 h. The equilibrium carrier diffusion length was > 100 nm, but the initial PCE was only 3.28%. It is proved that although the material has excellent stability, it has a disadvantage of low PCE. To improve the application value of the material in the photovoltaic field, Li *et al.*¹⁵ doped it with Cl and I. The results show that Cl doping at 25% concentration results a suitable band gap and enhances the stability of the system. Lu *et al.*¹⁶ studied a Si and Cl co-doped Cs₂TiBr₆ system by using the combination of non-adiabatic molecular dynamics (NAMD) and time-domain density functional theory (TD-DFT). The results show that doping avoids deep defects and inhibits electron hole recombination. It can be seen that doping is helpful to improve the photoelectric properties of Cs₂TiBr₆.

Herein, the Cs₂TiBr₆ material has been studied carefully using the first-principles method in many aspects. This work is the first comprehensive study to show that the electrical and optical properties of Cs₂TiBr₆ can be modulated by doping. It has been proved that doping with semi-metallic elements improves the photoelectric properties of perovskite materials.^{17–19} Besides, several teams^{20–24} pointed out that Cl doping is helpful to strengthen the stability of perovskite. However, there is no systematic and accurate description of the mechanism of doping effects. In this work, the physical stability and electrical properties of the Cs₂TiBr₆ material doped with different concentrations of semi-metallic elements Si, Ge, and Te, and halogen elements were

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studied. In order to obtain more accurate results, the GGA + U method²⁵ is employed for the calculations. This work not only overcomes the shortcomings of previous studies on the halogen-doped Cs₂TiBr₆ system but also investigates the doping effects of the Ti atom substitution by semi-metallic elements. Therefore, this work provides a significant guidance to develop and design high-performance all-inorganic lead-free perovskites.

2. Methods and models

First-principles simulations are performed using the VASP software package^{26,27} based on DFT. The wave function is expanded by the projected augmented plane wave method, and the exchange correlation interaction is treated by generalized gradient approximation (GGA) in the Perdew–Burke–Ernzerhof (PBE) method. The energy cutoff value is set to 520 eV, the force convergence standard is set to 0.01 eV Å⁻¹, and the energy convergence standard of self-consistent field (SCF) iteration is set to 10⁻⁶ eV. 8 × 8 × 8 *k*-point meshes are selected for the calculations. The strongly correlated electrons in Ti-3d orbitals are modified using the Hubbard U model.^{28–30} VASPKIT is used to process the calculated data,³¹ VESTA software is used to visually display the crystal structure, and LOBSTER software is used to calculate the crystal orbital Hamiltonian layout between two atoms.^{32–34} The Cs₂TiBr₆ model consists of 36 atoms with a space group of *Fm* $\bar{3}$ *m*. We have established 17 doping structures for halogen and semi-metallic doping. The doping positions are shown in Fig. 1.

3. Results and discussion

3.1 Geometry

After full relaxation for every structure, the lattice parameters of Cs₂TiCl₆, Cs₂TiBr₆, and Cs₂TiI₆ are 10.624 Å, 11.079 Å, and

11.878 Å, which are very close to the experimental values of 10.24 Å,³⁵ 10.92 Å¹³ and 11.67 Å,¹³ respectively. To analyze the physical stability of doping systems, the formation energy required for doping is calculated. The formation energy calculation formula is shown in eqn (1) and (2):³⁶

$$\Delta E = E_{\text{tot}}[X] - E_{\text{tot}}[\text{Cs}_2\text{TiBr}_6] + n_{\text{Br}}\mu_{\text{Br}} - n_x\mu_x \quad (1)$$

$$\Delta E = E_{\text{tot}}[X] - E_{\text{tot}}[\text{Cs}_2\text{TiBr}_6] + n_{\text{Ti}}\mu_{\text{Ti}} - n_y\mu_y \quad (2)$$

where $E_{\text{tot}}[X]$ and $E_{\text{tot}}[\text{Cs}_2\text{TiBr}_6]$ represent the total energy of Cs₂TiBr₆ cells with and without doping, respectively. μ_x refers to the chemical potentials of halogen Cl and I. μ_{Br} refers to the chemical potential of Br. The n_{Br} and n_x are the numbers of Br atoms and doped atoms, respectively. μ_y represents the chemical potentials of doped semi-metallic elements Si, Ge, and Te. μ_{Ti} represents the chemical potential of Ti. The n_{Ti} and n_y represent the numbers of Ti atoms and doped atoms, respectively. The formation energies obtained by calculations are shown in Fig. 2.

As shown in Fig. 2, the formation energy of Cl doping is negative, and those of I, Si, Ge, and Te doping are positive. It shows that it is easier to replace Cl with Br than the other elements. With the increase of doping concentration, the additional energy required for I to replace Br and the additional energies required for Si, Ge, and Te to replace Ti gradually increase. Thus, high concentration doping is not conducive to experimental preparation.

3.2 Electrical properties

In order to better explore the influence of doping on the electronic structure of Cs₂TiBr₆, the energy band and density of states of the doped structures were further analyzed. The Fermi levels in the energy band structures have been set to zero. Fig. 3(a) shows the energy band structure of the Cs₂TiBr₆ cell.

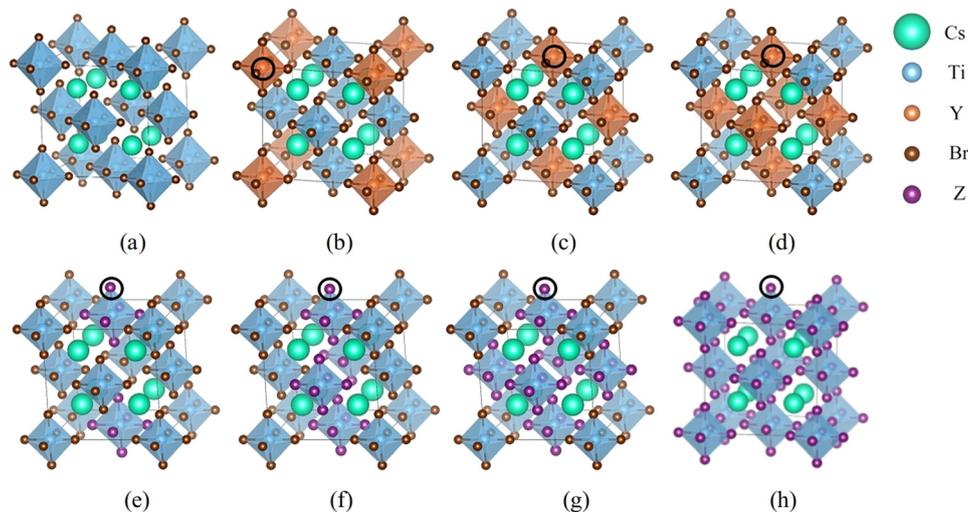


Fig. 1 Schematic diagrams of structures and doping positions. (a) The pristine Cs₂TiBr₆. (b)–(d) The semi-metallic doping models Cs₂Ti_{1-x}Y_xBr₆ (Y = Si, Ge and Te) with $x = 0.25, 0.5$ and 0.75 , respectively. The doping atoms are represented by orange balls located at the every center of orange octahedron. The locations are marked by black circles. (e)–(h) are halogen doping Cs₂Ti(Br_{1-x}Z_x)₆ (Z = Cl, I) with $x = 0.25, 0.5, 0.75$ and 1 , respectively. The doping atoms are represented by purple balls located at the octahedron vertex. The locations are marked by black circles. From (e) to (h) the doped octahedron increased from 1 to 4 in the supercell.



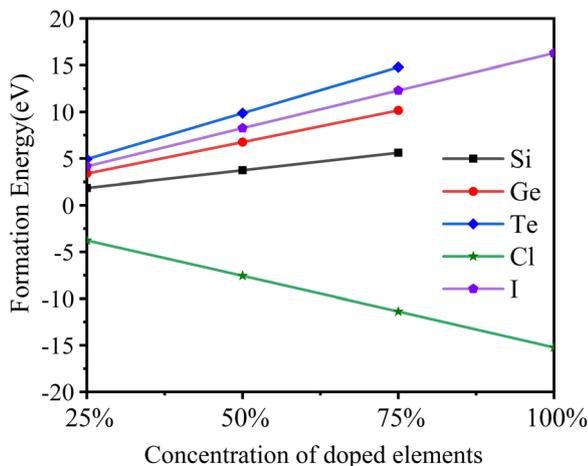


Fig. 2 Formation energies of different doping systems.

Actually, the band gap of Cs_2TiBr_6 is an indirect gap, which is called the quasi-direct band gap for the primitive cell. But the selected crystal cell having 36 atoms is 4 times of primitive one. So the gap looked like a direct band gap because of the band folding of the Brillouin zone in the supercell. Its band shape and band gap width are very consistent with those in the literature.³⁵ As shown in Fig. 3(b)–(d), the energy band structure of the system changes significantly after Ge doping. Ge doping results in an obvious impurity band in the forbidden band of the pristine system. The impurity band is contributed by Ge and Br, and its energy is lower than that of the impurity band contributed by the original system, becoming a new conduction band bottom. The impurity bands generated by Ge doping are close to the conduction band and the impurity band is a shallow impurity state. The shallow impurity level is conducive to the separation of optically excited electron hole pairs, and inhibits the recombination of optically excited carriers. For the 50% and 75% doping, the bottom curvature of the newly formed conduction band is significantly greater than that of the original system, which leads to the effective mass of electrons being less than that of the original system. The curvature in the valence band is basically unchanged. The band gap width of the 50% concentration is 1.33 eV, which evenly matches the optimum value.³⁷

Fig. 3(e)–(h) are schematic diagrams of the I doping energy bands. When I is doped, it directly replaces Br to form a new valence band top, and the conduction band bottom is contributed by I, Br, and Ti. With the increase of the concentration of the I atom, more and more energy subbands from I atom appear between the conduction band bottom and the valence band top of the pristine one. Therefore, the overall valence band is gradually raised and the band gap is decreased. This means a wider carrier diffusion length and better conductivity and better photoelectric conversion efficiency, compared with the pristine one. All doped structures are evaluated in terms of the energy band type and band gap value. When I is doped at 25%, the band gap of 1.29 eV is close to the S–Q theoretical³⁷ limit band gap of 1.34 eV. So that $\text{Cs}_2\text{Ti}_{0.5}\text{Ge}_{0.5}\text{Br}_6$ and

$\text{Cs}_2\text{Ti}(\text{Br}_{0.75}\text{I}_{0.25})_6$ can be expected as the optimal materials for solar cells.

In order to understand the change of band gaps in detail, the partial density of states (PDOS) of each doped structure is calculated for different orbits of the corresponding elements. As shown in Fig. 4(a), we can find that the band gap width of Cs_2TiBr_6 is mainly determined by the energy position of Ti-3d and Br-4p. The upper valence band is mainly contributed by the Br-4p orbital of elements because of its high electronegativity and the lower valence band is formed by the hybridization of the Ti-3d orbital and Br-4p orbital. The conduction band is formed by the hybridization of Ti-3d and Br-4p orbitals.

The Ge doping introduces Ge-4p state electrons into the upper and lower valence bands, respectively, as shown in Fig. 4(b)–(d). From -1.5 eV to 0 eV, the states in the valence band mainly come from the Ge-4p and Br-4p states, which expand the valence band bandwidth. The impurity energy level generated by the hybridization of Ge-4s and Br-4p electrons appears in the band gap, forming a new conduction band bottom due to the energy of the Ge-4s orbital being lower than that of the Ti-3d orbital. When valence band electrons absorb photons, the transition to the impurity level is more energetic for the low-energy photons, around 1.5 eV. With the increase of the Ge concentration, the impurity band is extended and the band gap decreases. However, the band gap of $\text{Cs}_2\text{Ti}_{0.25}\text{Ge}_{0.75}\text{Br}_6$ is smaller than the S–Q limit. This indicates that increasing the Ge concentration is not a linearly effective method to the application in the photovoltaic cells.

In Fig. 4(e)–(h), the proportion of I-5p increases with the I concentration. The valence band is gradually occupied by the electron of I-5p, which results in the valence band moving to the higher region. The conduction band shifts to a low energy level, so the band gap decreases gradually. In the conduction band of the $\text{Cs}_2\text{Ti}(\text{Br}_{1-x}\text{I}_x)_6$ system, the energy level of the Ti atom's electronegativity is smaller than that of I atoms. Therefore, the conduction band of the doped structure is mainly formed by the mixed states of the Ti-3d, Br-4p, and I-5p electrons.

3.3 Optical properties

The doping elements cause the change of the energy band structure, which certainly could affect the optical properties of Cs_2TiBr_6 obviously. The optical properties of solids are represented by dielectric functions:

$$\varepsilon(\omega) = \varepsilon_1(\omega) + i\varepsilon_2(\omega) \quad (3)$$

where ω is the frequency. $\varepsilon_1(\omega)$ and $\varepsilon_2(\omega)$ are the real and imaginary parts of the dielectric function, respectively. Absorption coefficient $\alpha(\omega)$, electron energy loss function $L(\omega)$ and reflection coefficient $R(\omega)$ can be calculated from the following equations:

$$\alpha(\omega) = \sqrt{2}\omega \left[\sqrt{\varepsilon_1^2(\omega) + \varepsilon_2^2(\omega)} - \varepsilon_1(\omega) \right]^{1/2} \quad (4)$$

$$L(\omega) = \frac{\varepsilon_2}{\varepsilon_1^2 + \varepsilon_2^2} \quad (5)$$



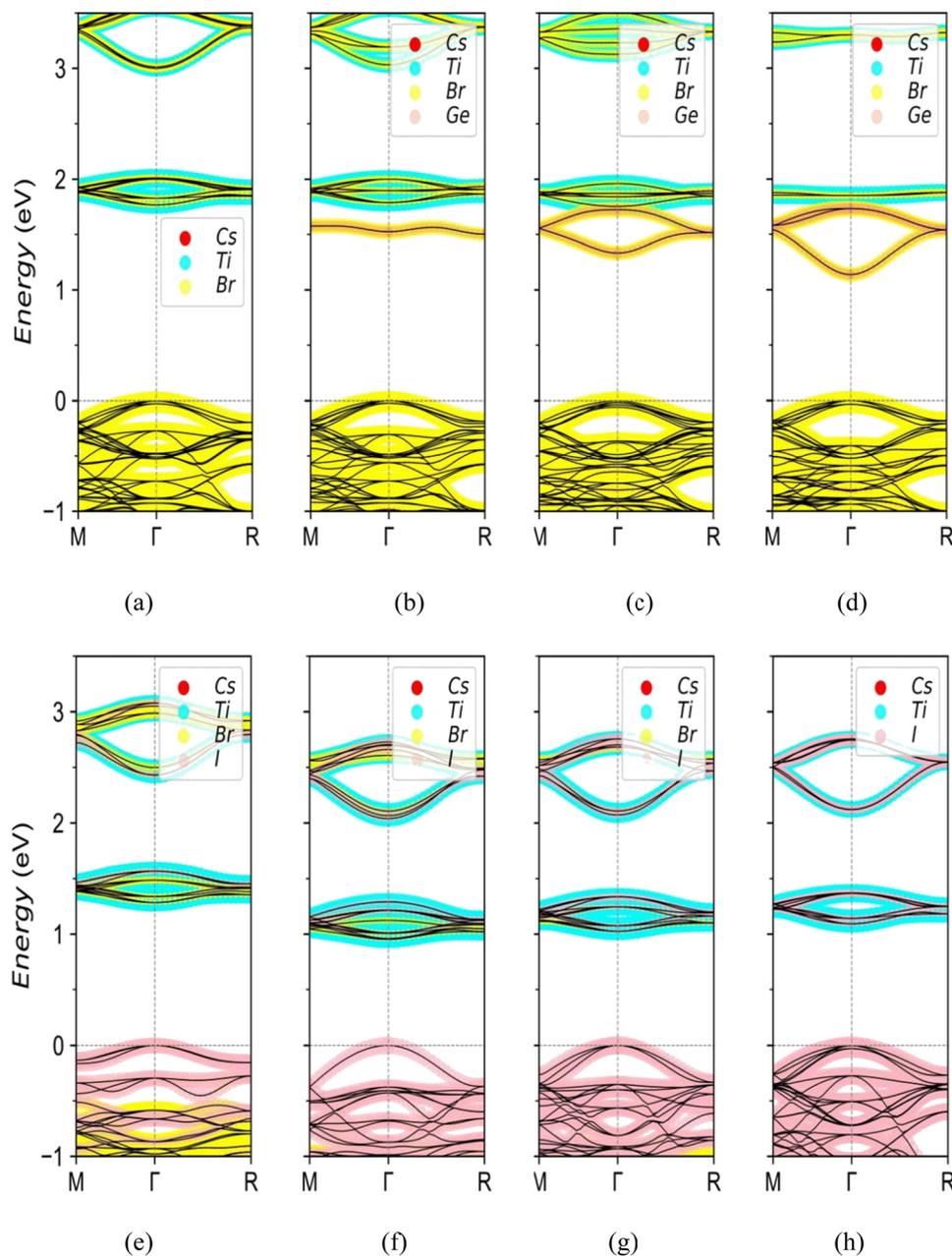


Fig. 3 Schematic diagrams of energy band structures. (a) Band structure of Cs_2TiBr_6 . (b)–(d) show $\text{Cs}_2\text{Ti}_{1-x}\text{Ge}_x\text{Br}_6$ ($x = 0.25, 0.5$ and 0.75), respectively. (e)–(h) $\text{Cs}_2\text{Ti}(\text{Br}_{1-x}\text{I}_x)_6$ ($x = 0.25, 0.5, 0.75$ and 1), respectively.

$$R(\omega) = \frac{(n-1)^2 + k^2}{(n+1)^2 + k^2} \quad (6)$$

When light propagates into the materials, the phenomenon of light attenuation occurs due to the absorption of the electrons. The optical absorption spectra of Cs_2TiBr_6 materials doped with different concentrations of are shown in Fig. 5. The results show that the absorption intensity of pure Cs_2TiBr_6 is the highest in the near ultraviolet region of 300–400 nm. The highest first absorption peak is at 340 nm. The second and third absorption peaks appear at 420 nm and 490 nm, respectively. According to the density of states diagram, the absorption peak is

formed by the interband transition from the electron absorption photon energy of the Br-4p orbital to the Ti-3d orbital. The light absorption capacity of the pure Cs_2TiBr_6 system decreased rapidly after 490 nm, which means most parts of the visible spectrum energy from the sun will be wasted.

Three semi-metallic elements Si, Ge, and Te have been used to substitute Ti in Cs_2TiBr_6 . But Ge is the only one that could expand the absorption spectrum obviously. As shown in Fig. 5(a), in the range of 300–594 nm, the light absorption capacity is almost reduced in equal proportion due to the doping of the Ge element. The Ge-4s orbital is incorporated into the original conduction band and Ti-3d orbital composition



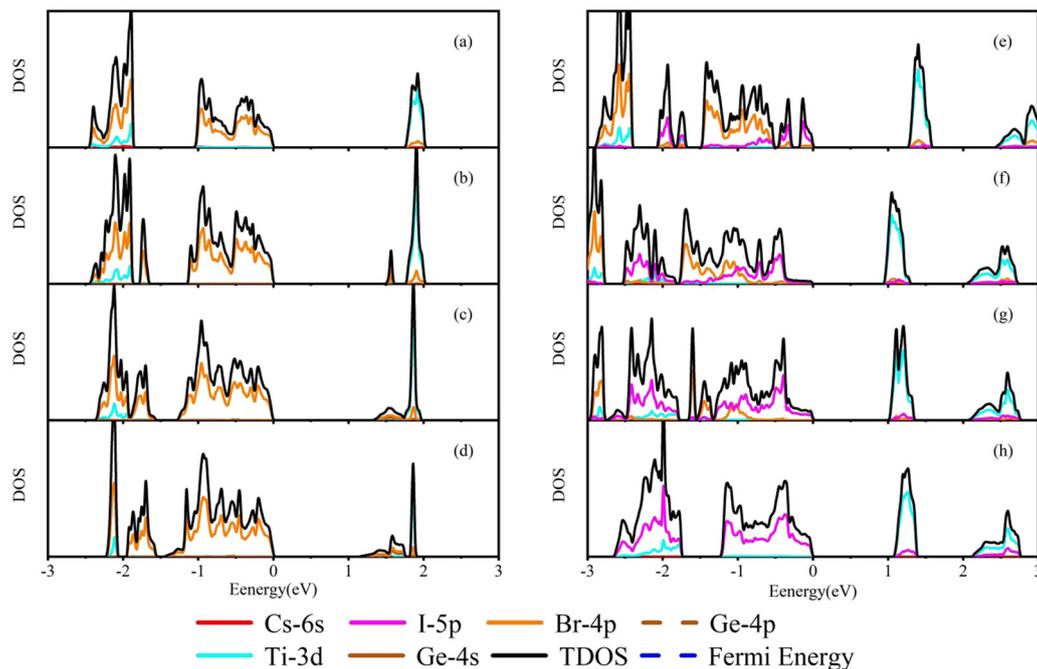


Fig. 4 Schematic diagrams of density of states. (a) Cs_2TiBr_6 . (b)–(d) $\text{Cs}_2\text{Ti}_{1-x}\text{Ge}_x\text{Br}_6$ ($x = 0.25, 0.5$, and 0.75), respectively. (e)–(h) $\text{Cs}_2\text{Ti}(\text{Br}_{1-x}\text{I})_6$ ($x = 0.25, 0.5, 0.75$ and 1), respectively.

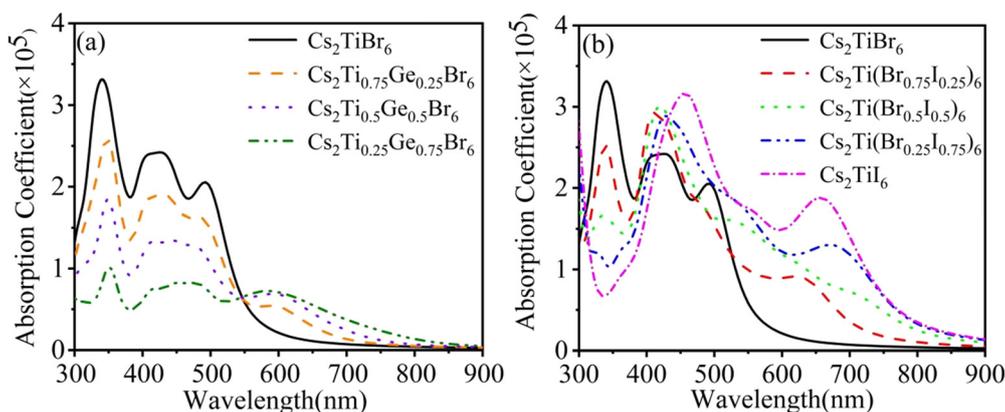


Fig. 5 Optical absorption lines. (a) $\text{Cs}_2\text{Ti}_{1-x}\text{Ge}_x\text{Br}_6$ ($x = 0.25, 0.5$ and 0.75). (b) $\text{Cs}_2\text{Ti}(\text{Br}_{1-x}\text{I})_6$ ($x = 0.25, 0.5, 0.75$ and 1).

is reduced. The electrons of Ge-4p and Br-4p states in the valence band undergo p-s transition and the poor degeneracy of the s orbital is much less than that of d orbital of Ti. Thus, the electron transition intensity is small. With the increase of doping concentration, the impurity band formed by the hybridization of the Ge-4s orbital and Br-4p orbital reduces the band gap and improves the light absorption capacity with a wavelength greater than 545 nm. The absorption peak appears at 594 nm, which is produced by the transition of electrons from Br-4p, Ge-4p valence bands to the Ge-4s impurity band. As the energy of photon decreases, the optical absorption coefficient decreases slowly.

After I atom doping, the band gap decreases, which is conducive to the doped system to absorb the photon of visible and near-infrared regions, as shown in Fig. 5(b). With the

increase of the I concentration, the absorption peak of the original system at a wavelength of 340 nm gradually moves to 420 nm. The absorption of the light at 550–900 nm gradually strengthens and an absorption peak emerges nearby 600 nm. The appearance of these absorption peaks proves that the optical absorption capacity is significantly improved by the doping of the I atom. It is interesting that the visible light is enhanced obviously, but the peak at 340 nm disappears when more than 50% Br is replaced by the I. The peak at 340 nm corresponds to the absorption of the photons with an energy of about 3.6 eV. We found that this energy corresponds to the energy gap between the valence band and the conduction band of Br. With the increasing concentration of I, the gap disappears gradually. So the 340 nm absorption band disappears.



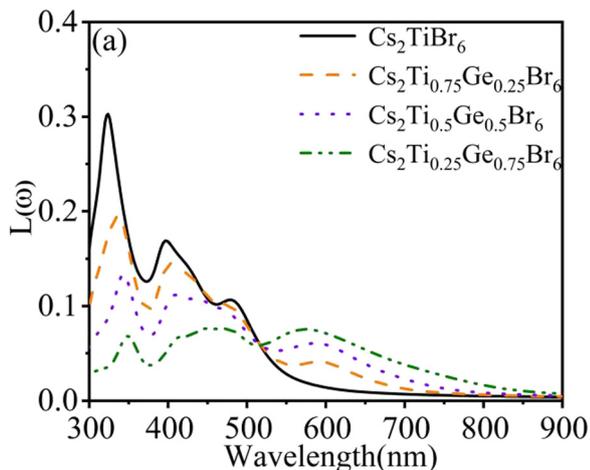


Fig. 6 Energy loss function. $\text{Cs}_2\text{Ti}_{1-x}\text{Ge}_x\text{Br}_6$ ($x = 0.25, 0.5$ and 0.75).

The higher value in the ultraviolet region overcomes the smaller absorption in the visible region for $\text{Cs}_2\text{Ti}(\text{Br}_{0.75}\text{I}_{0.25})_6$ than that of the rest of the three concentrations, considering the energy distribution of the solar spectrum.

The energy loss function $L(\omega)$ peak represents the characteristics related to plasma resonance absorption. It can be seen from Fig. 6 that the spectral line of energy loss function has a similar change trend to the light absorption coefficient. The pure Cs_2TiBr_6 has peaks at 325 nm, 400 nm, and 480 nm. When the wavelength is less than 517 nm, the energy loss function decreases gradually and the peak value of the energy loss function at 320 nm also decreases rapidly. The above shows that Ge doping reduces the probability of inelastic collision between electrons in the structure and photons in the 300–517 nm band. When the wavelength is greater than 517 nm, the energy loss peaks appear at 571 nm, 584 nm, and 592 nm. It shows that Ge doping is conducive to better use of low-energy photons and makes the electrons in the system interact with more low-energy photons.

4. Conclusions

In summary, the electronic and optical properties of the Cs_2TiBr_6 perovskite doped with Cl, I, Si, Ge, and Te are calculated using first-principles. The I and Ge doping are discussed in detail because of their great potential for improving the properties of Cs_2TiBr_6 . Ge doping is conducive to the separation of electron hole pairs. The quasi-direct band gap of the original system is adjusted to a direct band gap by 50% and 75% doping, which will increase the efficiency of sunlight absorption. The 50% Ge doped system has an optimum band gap of 1.33 eV and increases the absorption coefficient of sunlight with a wavelength greater than 550 nm. All the I doped systems have a direct band gap. The 25% concentration I doped system has the best band gap of 1.29 eV, enhancing the light absorption ability in the visible and near-infrared regions. $\text{Cs}_2\text{Ti}(\text{Br}_{0.75}\text{I}_{0.25})_6$ and $\text{Cs}_2\text{Ti}_{0.5}\text{Ge}_{0.5}\text{Br}_6$ are expected as the most potential solar light absorbing layer materials.

Conflicts of interest

We declare that none of the authors have any financial or scientific conflicts of interest with regard to the research described in this manuscript. We have no financial and personal relationships with other people or organizations that can inappropriately influence our work. There is no professional or other personal interest of any nature or kind in any product, service and/or company that could be construed as influencing the position presented in, or the review of the manuscript entitled.

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